

Coating process for ta-C on piston ring KIMS

Surface coating for tribological applications

- Coating Time: 1 batch/ 24 hr
(Semi-maintenance + cleaning + loading + coating)

Substrate cleaning



Ultra sonic cleaning



Baking

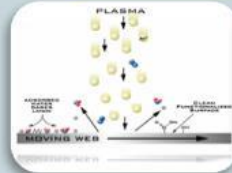
Sample loading



Heating to reducing outgassing
(120 °C up)

(1) Ion cleaning

- (Ion-source)
- Power : 2kV/700mA
- Etching rate : 300 nm



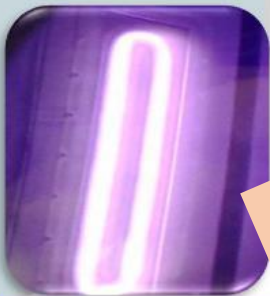
Coating Process

(3) ta-C coating

- Thickness : 5.0~6.0 μm



Control of Internal stress & Anti-wear



Control of Thermal stability

(2) Buffer layer coating

- (Magnetron Sputtering)
- Power : 8A/ 560 V
- Thickness : 0.7 ~ 1 μm

(4) Piston ring



Stable cathode usage



ta-C (FVAS) : New Technology & Market

□ Durability coating → To require the Functionality & Durability

